

Application Data Sheet

Application Information

Application Type:: Regular
Subject Matter:: Nationalization
Suggested Group Art Unit:: N/A
CD-ROM or CD-R?:: None
Sequence submission?:: None
Computer Readable Form (CRF)?:: No
Title:: PHASE SHIFT MASK, FABRICATION
METHOD THEREOF, AND FABRICATION
METHOD OF SEMICONDUCTOR
APPARATUS
Request for Early Publication?:: No
Request for Non-Publication?:: No
Small Entity?:: No
Petition included?:: No
Secrecy Order in Parent Appl.?:: No

Applicant Information

Applicant Authority Type:: Inventor
Primary Citizenship Country:: Japan
Status:: Full Capacity
Given Name:: Minoru
Family Name:: Sugawara
City of Residence:: Kanagawa
Country of Residence:: Japan
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Shinagawa-Ku

City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001

Correspondence Information

Correspondence Customer Number:: 23353

Representative Information

Representative Customer Number:: 23353

Domestic Priority Information

Application:	Continuity Type::	Parent Application::	Parent Filing Date::
This Application	National Stage of	PCT/JP03/08377	07/01/2003

Foreign Priority Information

Country::	Application number::	Filing Date::	Priority Claimed::
Japan	P2002-193168	07/02/02	Yes
Japan	P2002-200777	07/10/02	Yes

Assignee Information

Assignee name:: Sony Corporation
Street of mailing address:: 6-7-35 Kitashinagawa
City of mailing address:: Tokyo
Country of mailing address:: Japan
Postal or Zip Code of mailing address:: 141-0001